

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L12	37968	(BPSG or PSG or borophosphosilicate or phosphosilicate) or ((TEOS or silicate or glass or insulat\$6 or dielectric or ILD) near15 (reflow\$6 or (re adj flow\$6)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/16 15:49
L13	17640	12 and (SiN or Si3N4 or Si?sub??N?sub\$3 or (Si?sub\$3 adj N?sub\$3) or ((Si or silicon) adj nitride))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/16 15:50
L14	6916	13 and (@ad<"19980203" or @rlad<"19980203")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/16 15:51
L15	6808	14 and (interconnect\$6 or wiring or metalliz\$6 or metal or semiconductor or IC or (integrated adj circuit))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/16 15:51
L16	5873	15 and (SiO2 or SiO?sub\$3 or ((Si or silicon) adj (oxide or dioxide)) or TEOS)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/16 15:52
L17	2406	16 and (stress\$6 or strain\$6 or crack\$6 or peel\$6 or adhes\$6 or wrinkl\$6 or tensile or compress\$6)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/16 15:56
L19	940	17 and ((stress\$6 or strain\$6 or crack\$6 or peel\$6 or adhes\$6 or wrinkl\$6 or tensile or compress\$6) same (SiN or Si3N4 or Si?sub??N?sub\$3 or (Si?sub\$3 adj N?sub\$3) or ((Si or silicon) adj nitride)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/16 15:56